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LIST OF ART CITED BY APPLICANT

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Atty Docket No.	Serial No.		
A01187A	10/645,431		
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Richard Marti	n Jacobson et al.		
Filing Date August 21 2003	Group 1616		

U.S. Patent Documents EXAMINER DOCUMENT DATE Class/Subclass NAME FILING DATE IF NUMBER INITIALS **APPROPRIATE** $\overline{\mathsf{A}}\mathsf{A}$ 03/31/1992 SOZ 5,100,462 Sisler et al. 71/121 AB 5,518,988 05/21/1996 Sisler et al. 504/114 AC 6,017,849 01/25/2000 Daly et al. 504/114 AD 6.313.068 B1 11/06/2001 Daly et al. 504/114 AE 6,365,549 B2 04/02/2002 Sisler 504/114 SØ. AF 6,452,060 B2 09/17/2002 Jacobson 585/638 ĀG AH ·ΑΙ AK **FOREIGN PATENT DOCUMENTS** DOCUMENT DATE COUNTRY Class/Subclass Translation NUMBER Yes/No AL AM AN AO AP OTHER ART (Including Author, Title, Date, Pertinent Patents, etc.) Mark S. Baird, et al., The Preparation and Lithiation of 1-Halogenocyclopropenes, J. Chem. AR Soc. Perkin Trans. Vol. 1 PP 1845 - 1853 (1986) AS AT Examiner **Date Considered**

*EXAMINER: Initial reference considered, whether or not citation is in conformance with MPEP 609; draw line through citation if not conformance and not considered. Include copy of this form with next communication to applicant.

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